

AMENDMENTS TO THE SPECIFICATION

Please replace paragraph number [0015] on page 3 with the following rewritten paragraph:

[0015] The implant dose and diffusion drive time will determine the conductivity and depth of the channel regions ~~[[25]]~~ 24. At the same time that windows are opened in layer 16, a conductive polysilicon field plate 26 (an extension of layer 16) is also defined in the termination region.